

Peer Review

Review of: "Negative Capacitance Effect at the Interface Between Si Wafers with Undulating Surfaces"

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The paper is interesting and worthy of attention, but I find the following aspects need to be modified to make it clearer to a broader professional audience:

1. Below Figure 1, an explanation related to the image under section b should be provided.
2. In accordance with the explanation related to Figure 6, an equivalent circuit diagram to which it refers in the text preceding the figure should also be included.
3. The application of negative capacitance should be explained in more detail, rather than only briefly mentioning it at the very end as a passing comment. This change should also be incorporated into the abstract of the paper.

Declarations

Potential competing interests: No potential competing interests to declare.